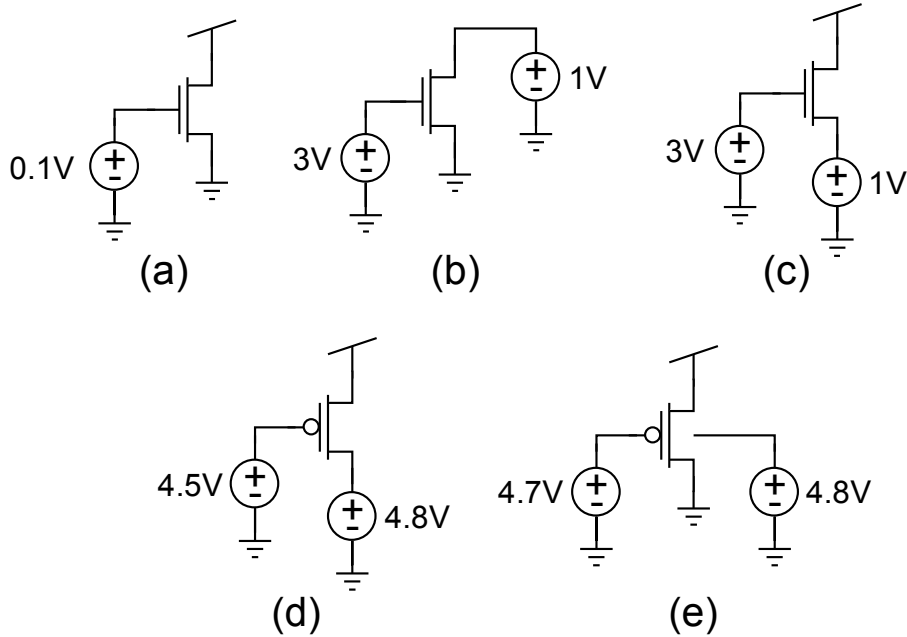


EE 551 Linear Integrated Circuits Homework 3

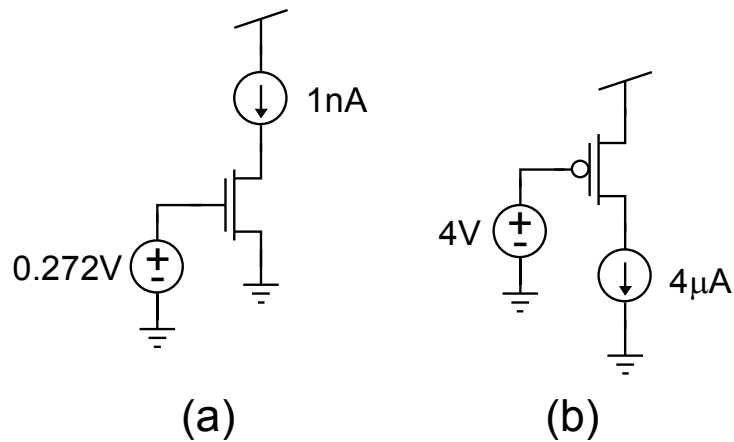
Unless otherwise specified, use the following transistor parameters.

$$V_{T0} = 0.7\text{V}, \gamma = 0.45\text{V}^{1/2}, 2\phi_F = 0.9\text{V}, \kappa_n = \kappa_p = 0.65 \text{ (subthreshold)}, \mu_n = 1360\text{cm}^2/\text{Vs}, \mu_p = 460\text{cm}^2/\text{Vs}, K = 100\mu\text{A}/\text{V}^2, I_0 = 1\text{pA}, I_{th} = 1\mu\text{A}, V_A = 50\text{V}, K_s = 11.8, \epsilon_0 = 8.854 \times 10^{-12}\text{F}/\text{m}, T = 300\text{K}, V_{dd} = 5\text{V}$$

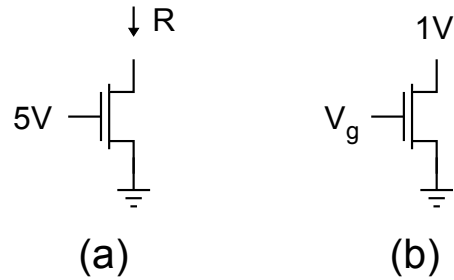
1. Determine the current flowing through each transistor.



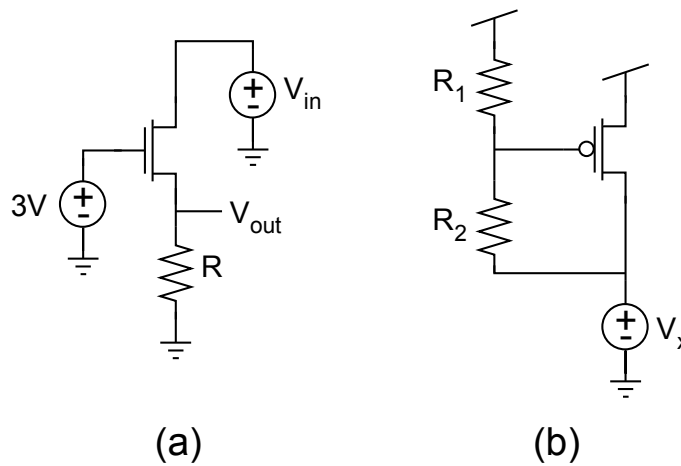
2. Determine the DC operating point of each transistor (i.e. determine the voltage at each node and the current flowing into/out of each node).



3. Create a resistive element from a transistor using the following information and the figures for the respective parts.



- a. What value of transistor width causes the transistor to have a resistance of 100Ω if $C_{ox} = 347\text{nF/cm}^2$, $L = 1\mu\text{m}$, and V_d is such that the transistor is operating in the deep ohmic region?
 - b. Determine the bias voltage required to create a $2.5\text{k}\Omega$ resistance, assuming $K = 100\mu\text{A/V}^2$.
4. Use the following figures for Parts a and b. For both parts, assume that $\gamma = \lambda = 0$ and also $I_0 = 0$ (no subthreshold current).



- a. Determine V_{out} when sweeping V_{in} from ground to V_{dd} (expressions and a sketch of values) for Figure a.
- b. Determine the channel current as V_x is swept from ground to V_{dd} (expressions and a sketch of values) for Figure b.